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Supplementary Material Available: Spectral data (IR, ^1H NMR, and MS) for compounds 8-16, 18, and 20, tables of fractional coordinates, bond distances, torsional angles, and anisotropic temperature factors and summary of the X-ray crystallographic determinations and structures of compounds 13 and 20 (17 pages). Ordering information is given on any current masthead page.

Molecular Sieve Sensors for Selective Detection at the Nanogram Level

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Zeolites have long been known for their molecular sieving properties based upon crystalline pore structures of molecular dimensions.¹ We explore strategies to introduce *molecular sieving functions into inorganic thin films* and membranes which are of current interest for sensor coatings and gas-phase separations.²⁻⁴ The zeolite films offer high thermal stability (>770 K) and chemical resistance. Surface acoustic wave (SAW, Figure 1A) devices⁵ can be operated as highly sensitive piezoelectric balances that respond to small fractions of single-crystal monolayer adsorption via frequency changes of an oscillator circuit. Since the response is nonselective, a number of organic and organometallic coatings on SAW devices have previously been explored to impart chemical selectivity.⁶ The SAW device^{7,8} (97 MHz, detection limit ca. 100 pg/cm²) used in the present study to measure selective adsorption of organic vapors (0.1% of saturation in nitrogen flow, 295 K) consists of a single-crystal quartz substrate with interdigital transducers which was coated with zeolite-silica thin films and mounted in a test chamber with gas inlet and outlet.

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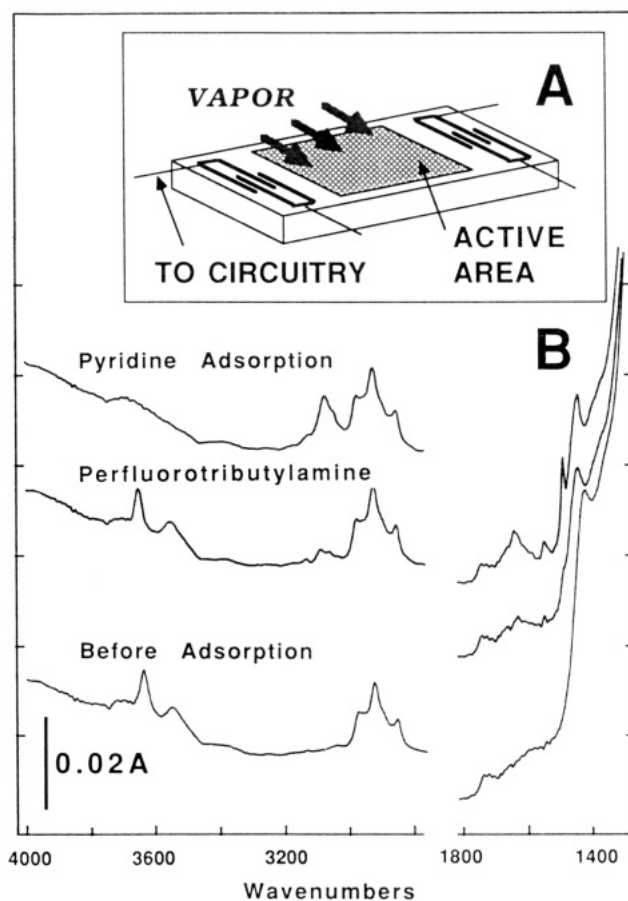


Figure 1. A. Schematics of the surface acoustic wave device. B. Adsorption of pyridine and perfluorotributylamine vapor (1 Torr at 295 K) on HY-zeolite film embedded in silica matrix derived from base-catalyzed sol (B2), degassed at 570 K, 10^{-7} Torr. FTIR spectra were taken at 8-cm^{-1} resolution in a stainless steel UHV cell, equipped with CaF_2 windows and connected to a steel apparatus with turbomolecular pump and mass spectrometer. The features in the C-H stretch region (ca. $2800\text{-}3000\text{ cm}^{-1}$) are due to decomposition products of the sol matrix deposited on the cell windows after initial heating.

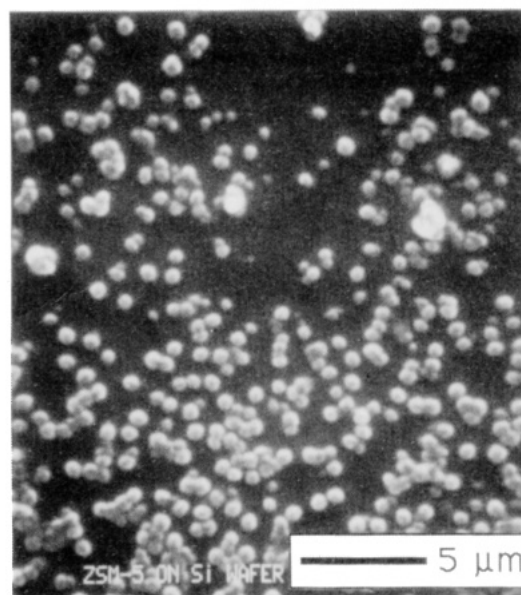


Figure 2. Scanning electron micrograph of crystals of zeolite H-ZSM-5 embedded in an A2-sol derived matrix¹⁶ on a Si wafer.

The zeolite-silica composites are prepared from suspensions of small zeolite crystals in alcoholic solutions of tetraethylorthosilicate (TEOS) that is hydrolyzed and polymerized by acid- and base-catalyzed reactions resulting in extended, weakly branched

structures or compact, colloidal particles, respectively.^{9,10} During deposition of the zeolite/silicate suspensions by dip-coating, the solvent is evaporated, and the silicate films gel, "freezing in" the incorporated zeolite crystals (Figure 2). Final consolidation of the porous matrix structure to a nonporous film occurs by viscous sintering.^{11,12}

The molecular sieving behavior of zeolite Y¹³ (Y, crystal size, 0.2 μm ; pore size, 7.5 \AA), chabazite¹⁴ (CHA, crystal size, 1-3 μm ; pore size, 3.7 \AA), ZSM-5¹⁵ (crystal size, 0.5 μm ; pore size, 5.4 \times 5.6 \AA), and zeolite A (LTA, crystal size, 3 μm ; pore size, 4.1 \AA) crystals is maintained when they are embedded in TEOS sol-gel derived glassy thin films.^{16,17} For example, the acid form of zeolite Y¹⁸ embedded in a silicate-based film adsorbs pyridine (5.9 \AA kinetic diameter) as shown by consumption of the intrazeolite bridged hydroxyl groups (at 3540 and 3640 cm^{-1}) and the formation of pyridinium ions (band at 1545 cm^{-1} ; Figure 1B). However, exposure of a similar film to perfluorotributylamine (10.2 \AA) does not indicate any reaction with the internal bridged hydroxyls. Similarly, acidic chabazite-based films (pore size 3.7 \AA) react with ammonia (2.6 \AA) but not with tributylamine (8.1 \AA).

The selectivity of zeolite films is maintained even in aqueous systems. For example, pyridine or NH_3 diffused into Cu(II)-containing faujasite-silica thin films¹⁹ from aqueous solution coordinate to intrazeolite Cu(II) to form $[\text{CuL}_4]^{2+}$ complexes as shown by the appearance of corresponding ligand vibrations, e.g., at 1610, 1543, 1487, and 1450 cm^{-1} for $[\text{Cu}(\text{py})_4]^{2+}$. When CHA (3.7 \AA) or LTA (4.1 \AA) are incorporated in the glassy matrix, pyridine is completely excluded from the pores. In aqueous phase, the pyridine molecules bind selectively to Cu-FAU films but not to the corresponding Na or NH_4 forms.

Having demonstrated the chemical and size-based molecular selectivity of zeolite-silica films, we present the first application of these films as coatings on SAW devices. We note that thin silica films alone, processed similarly, have extremely low porosity (<2%) and surface areas (1 cm^2/cm^2).⁸ A glassy silica matrix of ca. 150 nm thickness, embedding crystals of ZSM-5 (pore size 5.4 \times 5.6 \AA), was coated on the active surface of a SAW device. A striking difference in frequency response to different probe molecules was observed. While vapors of MeOH (ca. 3.8 \AA kinetic diameter) and PrOH (ca. 4.7 \AA) adsorb at levels of 500-800 ng/cm^2 in the film, the response to isooctane (2,2,4-trimethylpentane; 6.2 \AA) is minimal (below 5 ng/cm^2). This dramatic difference can be understood if the kinetic diameters of these molecules are compared to the pore size of the zeolite film. The amount of vapor adsorbed in the film is in reasonable agreement with that calculated from crystal area densities observed in electron micrographs.

We have established that (i) zeolite-silica thin films with molecular sieving properties can be prepared, (ii) the films can be modified such that different chemical selectivities result, and (iii) these zeolite films can be utilized to introduce chemical selectivity to highly sensitive surface acoustic wave devices. Other zeolite thin film coatings with modified chemical selectivities are presently being explored.

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Novel Anionic Polymerization of Masked Disilenes to Polysilylene High Polymers and Block Copolymers¹

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Polysilylenes, the linear silicon-silicon bonded polymers, have several interesting properties and are a subject of current intense investigations.² Polysilylenes are prepared mostly by the Wurtz-type coupling reactions of dichlorodialkylsilanes which, however, have several difficulties such as the poor control of structure, molecular weight, and polydispersity. The yields of polymers are also usually low.⁷ In this paper, we will describe an entirely novel method of preparing polysilylenes based on anionic polymerization of masked disilenes.⁹

After examination of several possibilities, we have found that 1-phenyl-7,8-disilabicyclo[2.2.2]octa-2,5-dienes (**1b-1d**) can be used for anionic polymerization.¹³ Alkylolithiums such as *n*- and

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(16) Silica sols were prepared from a stock solution of 61.0 mL of TEOS (tetraethylorthosilicate), 61.0 mL of EtOH, and 5.0 mL of 0.04 M HCl. For the preparation of A2 sol, 10 mL of the stock solution was combined with 0.12 mL of 1.0 M HCl and 0.4 mL of H₂O. B2 sol was obtained by adding 1.0 mL of 0.05 M NH_4OH to 10 mL of the stock solution. See: Brinker, C. J.; Keefer, K. D.; Schaefer, D. W.; Assink, R. A.; Kay, B. D.; Ashley, C. S. *J. Non-Cryst. Solids* **1984**, *63*, 45.

(17) Dip-coated composites were made from suspensions of 0.5-2.5 g zeolite in 2.5 mL of silica sol which was diluted with 5 mL of EtOH and coated on Si wafers at 50 mm/min vertical pulling rate. All wafers were dried in air at 360 K.

(18) Obtained by degassing the NH_4 -exchanged form at 670 K in vacuo.

(19) Zeolites were 50% ion-exchanged with 0.1 M $\text{Cu}(\text{NO}_3)_2$ prior to dispersion in the sol.

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(9) Conceptually, polymerization of disilenes, the silicon-silicon double bonded species, may be a straightforward route to linear polysilylenes. It is not possible in practice though, because disilenes are not stable enough to be isolated except for those with very bulky substituents.¹⁰ Incidentally, 7,8-disilabicyclo[2.2.2]octa-2,5-dienes have been known as precursors of disilenes; Roark and Peddle¹¹ reported generation of disilenes by thermolysis of **1a**. We have also reported that a 2,3-benzo-7,8-disilabicyclo[2.2.2]octa-2,5-diene system afforded *cis*- and *trans*-1,2-diphenyl-1,2-dimethyldisilenes by thermolysis.¹² Therefore, we have expected that these 7,8-disilabicyclo[2.2.2]octa-2,5-diene systems could behave as masked disilenes even in ionic reactions.

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